## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Hiroto OHTAKE, et al.

Appln. No.:

10/080,848

Art Unit:

1765

Filed:

February 22, 2002

Examiner:

DEO, Duy Vu Nguyen



METHOD OF MANUFACTURING A SEMICONDUCTOR DEVICE CAPABLE OF ETCHING A MULTI-LAYER OF ORGANIC FILMS AT A HIGH SELECTIVITY

Docket No.:

KRM-00101

## **Certificate of Mailing**

I hereby certify that the foregoing documents are being deposited with the United States Postal Service as first class mail, in an envelope addressed to the Commissioner for Patents; P.O. Box 1450, Alexandria, VA 22313-1450 on this date of January 25, 2005.

## PETITION FOR EXTENSION OF TIME

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450 Sir:

This is a request to extend the period for filing a response in the above-identified application for one month from <u>January 7, 2005</u> to <u>February 7, 2005</u>. Enclosed is a check for \$120.00 to cover the extension fee.

Although we believe that we have submitted the correct amount to cover the requested extension of time, the Commissioner is authorized to credit any overpayment or charge any deficiencies to our **Deposit Account No. 031721**. Two originally-executed copies of this form are being submitted.

Should there be any questions after reviewing this paper, the Examiner is invited to contact the undersigned at (617) 248-4038.

01/31/2005 HALI11

00000056 10080848

01 FC:1251

120.00 OP

January 25, 2005

Date

Donald W. Muirhead Reg. No. 33,978

Respectfully submitted

Customer No.: 26339

Patent Group

Choate, Hall & Stewart

Exchange Place

53 State Street

Boston, MA 02109

3790734\_1.DOC